

David W. Collins

711 West Los Altos Road
Tucson, AZ 85704-4105

Sheet 1 of 2

FORM PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. D-95013A1a	SERIAL NO. (Filed Herewith)
LIST OF PRIOR ART CITED BY APPLICANT		APPLICANT		
		Ahmad Waleh et al		
		FILING DATE (Filed Herewith)	GROUP	

U.S. PATENT DOCUMENTS

EXR IN		DOC. NO.	DATE	NAME	CLASS	SUBCLASS
<i>Ay</i>	AA	4,669,544	6/1/87	Nimerick	166	300
	AB	5,030,399	7/9/91	Walles et al	264	83
	AC	5,158,100	10/27/92	Tanaka et al	134	105
	AD	4,179,071	12/18/79	Kozacka	239	397.5
	AE	4,915,912	4/10/90	Walles et al	422	160
	AF	4,778,536	10/18/88	Grebinski	134	36
	AF1	5037506	8/1991	Gupta, et al	134	902
	AG	4,363,673	12/1982	Settineri, et al	134	2
	AH	4,455,175	12/1984	Settineri, et al	134	5
	AI	4,536,222	8/1985	Settineri, et al	134	5
	AJ	5,763,016	12/1998	Levinson, et al	427	510
	AK	5,952,157	9/1999	Kato, et al	430	329
<i>Ay</i>	AL	5,227,001	7/13/93	Tamaki, et al	156	345

FOREIGN PATENT DOCUMENTS

		DOC. NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION
							YES
	AN						
	AO						
	AP						

OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

<i>Ay</i>	AR	Stanley Wolf and Richard N. Tauber, "Silicon Processing For The VLSI Era", <i>Process Technology</i> , Vol. 1 (1986), p. 564;
	AS	"Choose The Right Process To Strip Your Photoresist", <i>Semiconductor International</i> , February 1990, pp 63-67;
	AT	"New Concerns In Dry Oxygen Ashing", <i>Semiconductor International</i> , March 1996, p. 44; and
	AU	"What's Driving Resists Dry Stripping?", <i>Semiconductor International</i> , November 1994, pp 61-64.
	AV	Christina M. Cline, "Emerging Technology; Emerging Markets", <i>Precision Cleaning</i> , October 1996, pp 11-19
<i>Ay</i>	AW	Ruth DeJule, "Managing Etch and Implant Residue", <i>Semiconductor International</i> , August 1997, pp 56-63

EXAMINER	<i>A. MARCUCCI</i>	DATE CONSIDERED
		<i>10/28/07</i>

EXAMINER: Initial if references considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

PATENT APPLICATION
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FORM PTO-1449	ATTY. DOCKET NO.	D-95013A1	SERIAL NO.	(Filed Herewith)
	APPLICANT	Ahmad Waleh, et al.		
	FILING DATE	(Filed Herewith)		GROUP

REFERENCE DESIGNATION U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS
<i>AM</i>		3893869	7/1975	Mayer, et al	134	184
		5024968	6/1991	Engelsberg	134	1
		5114834	5/1992	Nachshon, y	216	48
		5531857	7/1996	Engelsberg, et al	134	1
<i>AM</i>		5643472	7/1997	Engelsberg, et al	134	1

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLAS	TRANSLATION	
							YES	NO
<i>AM</i>		WO9507152	3/1995	Elliott et al	B08B	3/00	x	
<i>AM</i>		WO9717164	5/1997	Genut et al	B23K	26/6	x	

OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.)

<i>AM</i>	Hawley's Condensed Chemical Dictionary, P 28, 1993
<i>AM</i>	Egelsberg, "Laser Assisted Cleaning Proves Promising", Precision Cleaning, 1994

EXAMINER *R MARSHALL* DATE CONSIDERED *10/28/97*